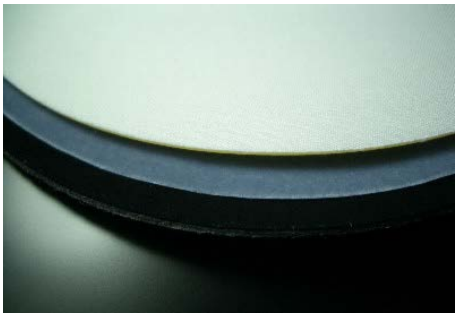
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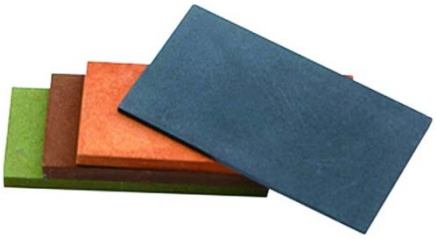
Polishing pad and Dressing board

SUNTEK Polishing pad is produced by electrostatic planting technology and precise coating technology. It is used for lapping, polishing and finishing optical element, sapphire and ceramics.



Abrasives	Application	dimension
no	Fiber Optic	Φ70, Φ110mm Φ127, Φ203mm
Silicon Oxide	Fiber Optic	
Aluminum Oxide	Steel Roller	114mm*114mm 152mm*152mm2 28mm*280mm

SUNTEK Dressing board of grinding wheels for wafer, which has good dressing effect and high parallelism on grinding wheel.



Dressing mode:

Adsorption and hand-held

Specification:

3, 4, 5, 6, 8, 12 inches.

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